

**AMENDMENT UNDER 37 C.F.R § 1.116  
EXPEDITED PROSECUTION - ART GROUP 1795**

03500.518677

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

SHOJI SHIBA, ET AL.

Application No.: 10/577,218

Filed: April 26, 2006

For: PHOTSENSITIVE RESIN  
COMPOSITION, METHOD OF  
FORMING LEVEL DIFFERENCE  
PATTERN USING THE  
PHOTSENSITIVE RESIN  
COMPOSITION, AND METHOD  
OF PRODUCING INK JET HEAD

Examiner: Anca Eoff

Group Art Unit: 1795

Confirmation No.: 3411

Date: December 16, 2008

*Enter MCG  
01/15/09  
AS*

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

~~DO NOT ENTER: /A.E./~~

~~12/22/2008~~

AMENDMENT AFTER FINAL REJECTION

Sir:

a) Introductory Comments:

In response to the final Official Action dated September 18, 2008, kindly  
amend the above-identified application as follows.